




Configurable Sintered Interconnect
(CSI™) for Semiconductor Packaging




About EoPlex

- Headquartered in San Jose, CA
- Subsidiary of ASTI since 2012
 - 14 factories, 4 R&D centers located in 8 countries
 - 2,300 employees world wide
- Production Facilities in Penang
- Expanding Manufacturing Capability in Cavite, Philippines - Q3 2015
- Creator of 3D High Volume Print Forming process (HVPF™) for multi material 3D printing

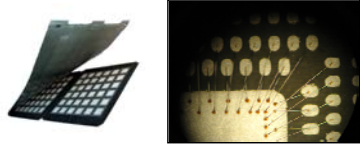


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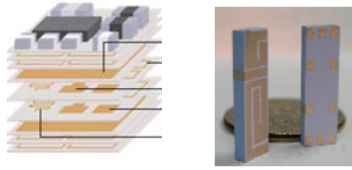


3D HVPF™ Product Areas


Semiconductor Packaging Configurable Sintered Interconnect (CSI™)




Internet of Things: Micro Antenna





Fluidics



Energy Harvesters

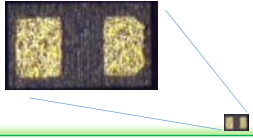


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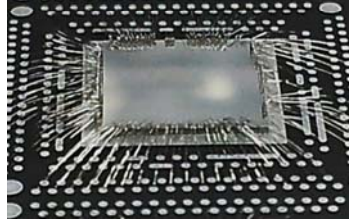


CSI™ Vehicle for Packages with Lead Counts from 2 to 500 +

01005 (.4mm X .2mm), 2 lead




12mm X 12mm, 224 Leads, 437 wires




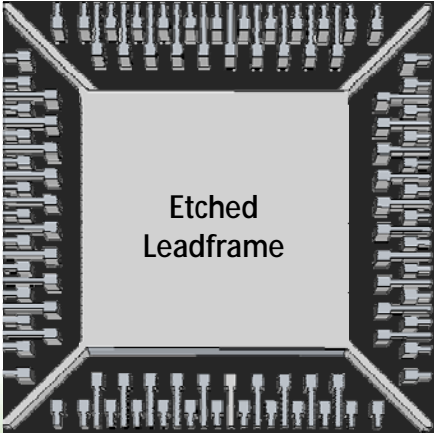
CSI™ Package Benefits

- ✓ Wide lead count range
- ✓ Min. metal = higher performance
- ✓ Improved thermals
- ✓ Finished package to $\leq 250\mu$ thin
- ✓ Design flexibility


CSI™ QFN replaced
4 layer BGA

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 **CSI™ Eliminates Tie Bars**
Package Shrinks, Electricals Improve





Etched Leadframe



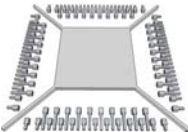
CSI™ Platform Superior Design

Allows for more complex interconnect

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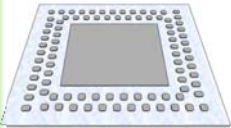
 **CSI™ - Array of Package Components on a Temporary Carrier**

Std Lead Frame

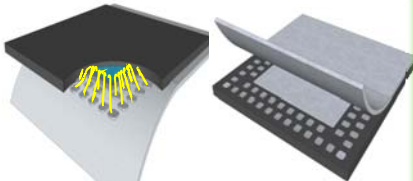


Tie bars stay with finished package: poor signal integrity

CSI™ LeadCarrier





CSI™ : leads on temporary carrier



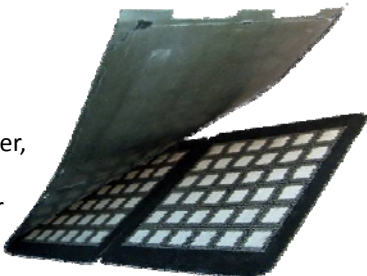
Carrier removed leaving only metal for interconnect


The carrier provides needed mechanical properties, Leads are only as thick as required – nominally 40μ


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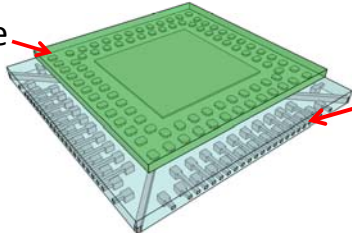
 **Temporary Carrier Improves the Process and the Product**

- A Better Process
 - Steel carrier is cheap and robust
 - The carrier eliminated the need for tape
 - Displacement of leads in any direction is virtually eliminated
 - All pads are securely bonded to the carrier, eliminating deflash
 - Pads are electrically isolated after carrier removal allowing for test in strip form
 - Singulation requires cutting only EMC
- A Better Product
 - Thinnest possible pads (40μ) means thinnest possible package ($<250\mu$)
 - Residual tie bars are eliminated
 - Greatly expand design freedom




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 **CSI™ Based Packages Have Smaller Footprints and Less Volume/Mass**

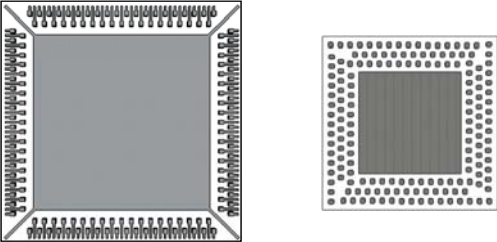
88 lead package based on CSI™  88 lead package based leadframe

- This CSI™ based package example has:
 - 23% smaller footprint
 - 50% less volume
 - 66% less mass

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CSI™ is Even More Efficient with More Than Two Rows



156 ld. Leadframe
9 mm DAP

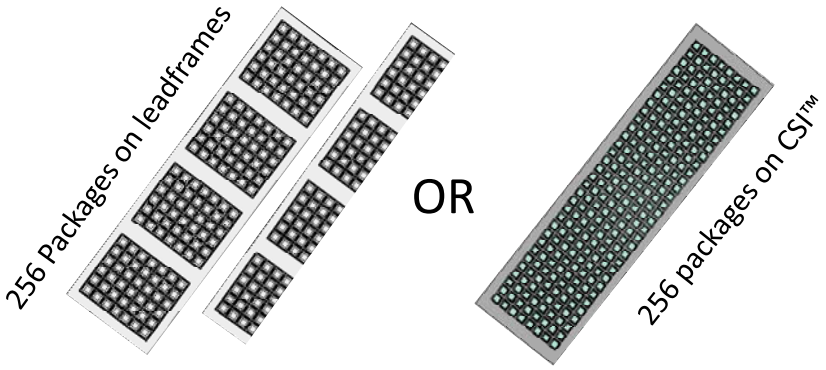
160 ld. CSI™
5.25 mm DAP

- Most die don't need the DAP size available in dual row QFN
- With three row CSI™:
 - 44% smaller footprint than with dual row leadframe
 - 130% more package sites per 70mm x 250mm strip
 - Average wire bond length is at least 2mm shorter

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More Efficient Use of Strip Space Lower Cost Per Package Site



256 Packages on leadframes

OR

256 packages on CSI™

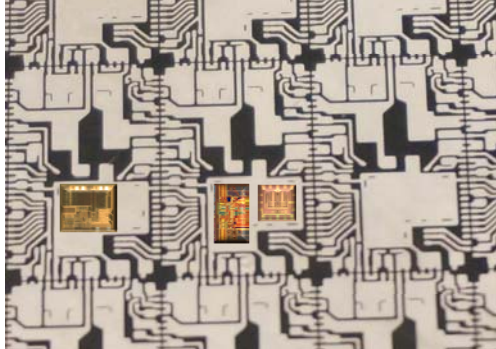
CSI™ strip allows 52% more leadframes

Based on 88 lead package sites on 70mm X 250mm strips

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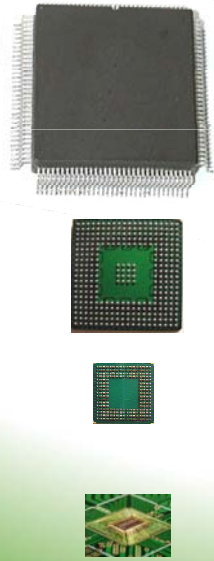
EoPlex Previously Impossible Design Options
On a Single layer

- Multiple rows
- Multiple DAPs
- Floating structures
- More than 500 leads
- 300 μ bond pad pitch
- 200 μ interconnect pitch
- Wetable flank for solder inspection



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EoPlex CSI™ Addresses Mobility Market
Smaller, Thinner Form Factor



Package Type	Footprint	Thickness	Electrical Performance	Cost	Lead Count	Pad Pitch
QFP	Big Footprint	Very Thick	Poor Electrical			
BGA	Big Footprint	Thick	Poor Electrical			
fBGA	Thick		Poor Electrical	Expensive		
DCA	Limited Applicability					

CSI™

- 250 microns thin
- 2 to 500+ leads
- 300 microns solder pad pitch

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CSI is Fully Compatible with Standard QFN Infrastructure

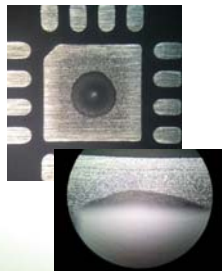
No Etching or plating required



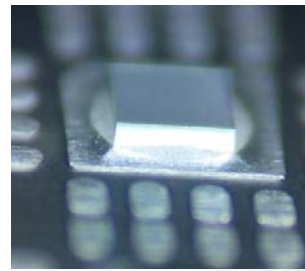
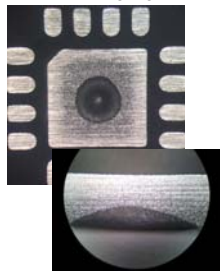
Uses Standard Die Attach Materials


Excellent Die attach performance,
strong adhesion of die to silver bond pad

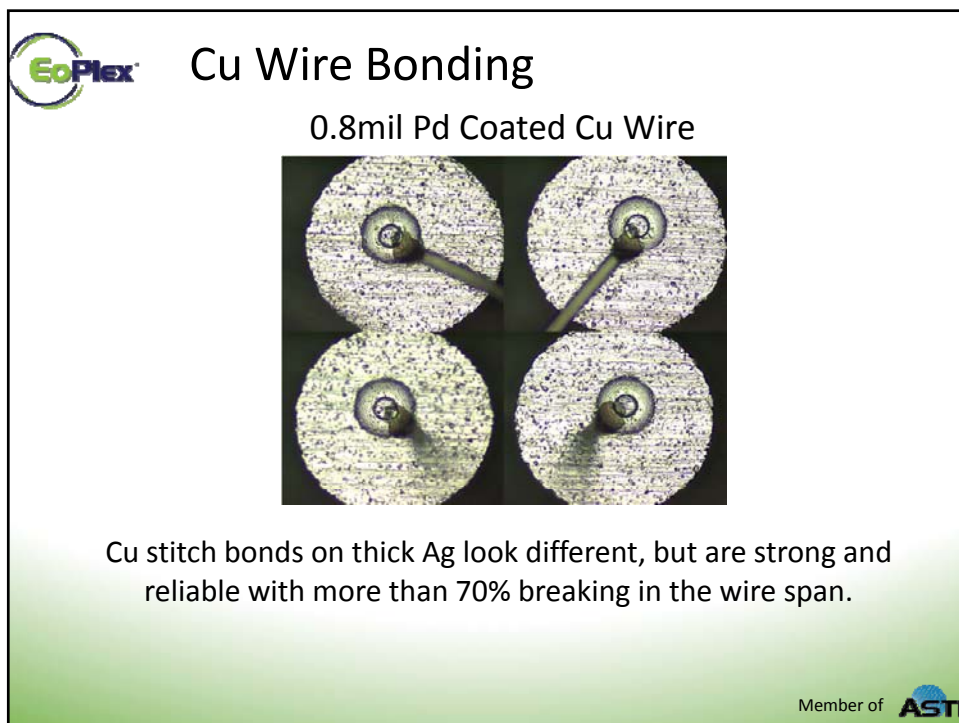
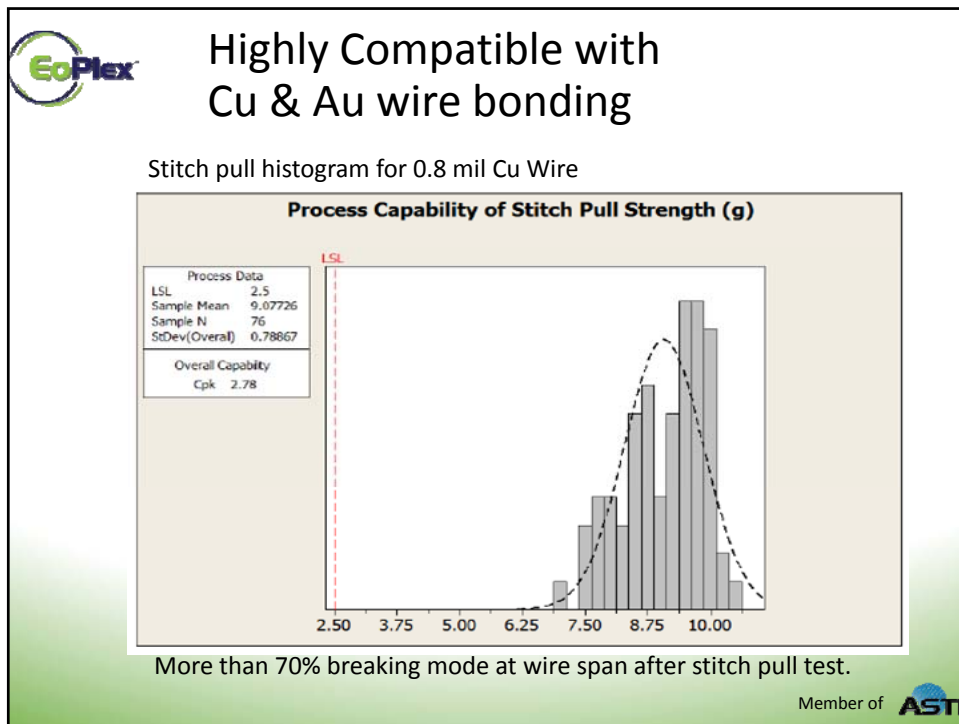
0 hrs



3 hrs staging




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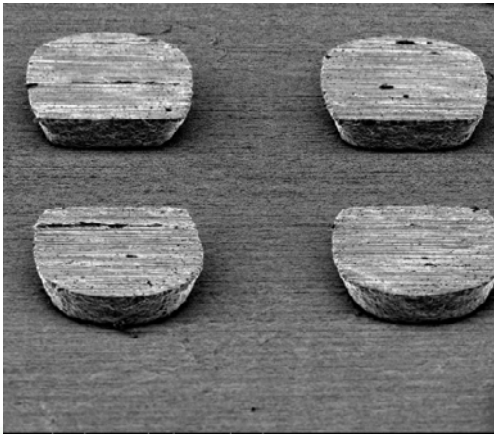
 Works with Standard QFN
Molding Materials and Process




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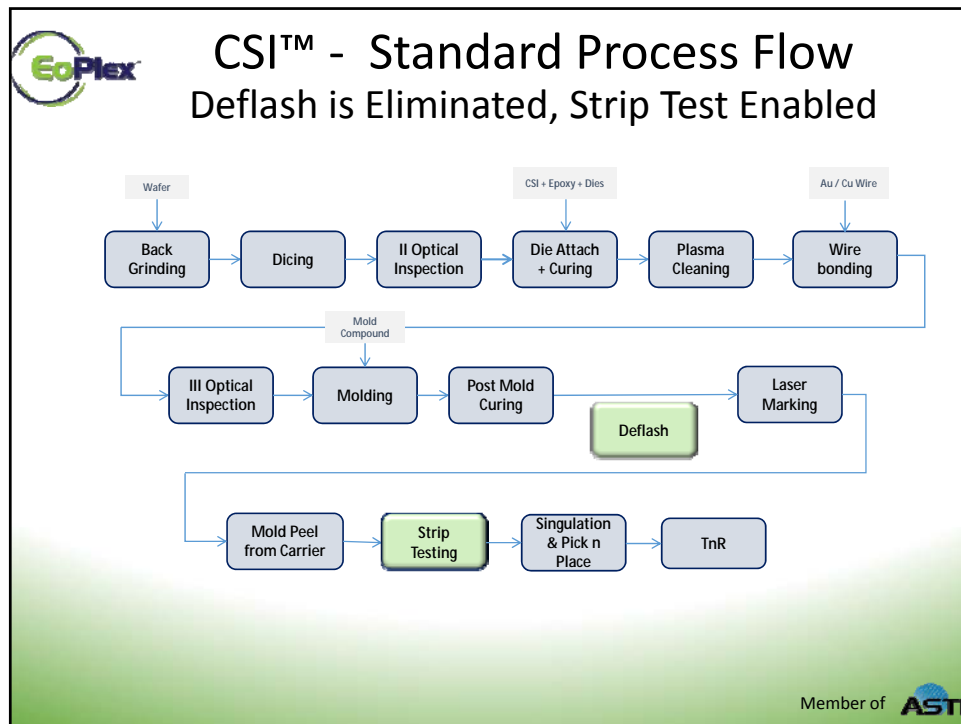
 Pad Shape Provides Lock-in Feature and
Surface Texture Improves MSL Performance

- Surface roughness of sintered silver improves adhesion
 - Die Pad Avg : 0.87um
 - Bond Pad Avg : 0.45um
- Conical frustum shaped pads
 - Excellent locking of Leads with mold compound



HV Spot WD Det 08/12/13 Mag
10.0 kV 5.0 32.28 mm Etd 10.41.17 320x

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EoPlex™ **CSI™ Platform Reliability Matrix**

Test	Conditions	Status
Biased HAST	130°C, 85% rh, 5v, 96 hr	PASSED
Solderability	Per JESD22-B102E, Cond. A, Method 1, Pb free	PASSED
MSL JEDEC Level 1	85°C / 85% rh, 168 hr.	PASSED ¹
MSL JEDEC Level 3	30°C / 60% rh, 192 hr.	PASSED ²
High Temp Storage	150°C, 1,000 hr.	PASSED
Temp/Humidity	85°C / 85% rh, 1,000 hr.	PASSED
Temp Cycle	-65°C to 150°C, 500 cycles, 30 min. /cycle	PASSED

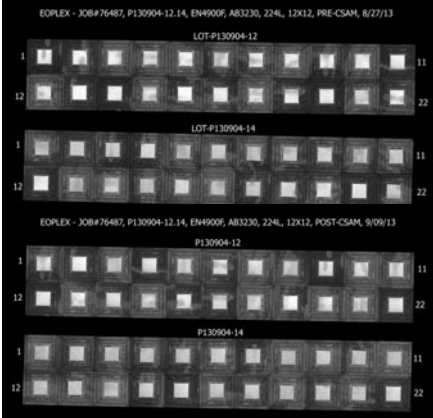
Notes:
1) Package size and BOM dependent
2) BOM dependent

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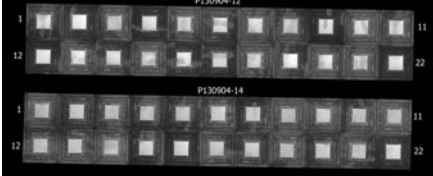


MSL results on 224 Lead, 12x12 Package built on CSI™ Platform


Description		
Build	P130904 – 12	P130904 – 14
Package	224L 12x12 / 44 units	224L 12x12 / 44 units
Die Size	5x5 mm	5x5 mm
Epoxy	Hitachi EN4900F	Able bond 3230
Plasma	With Plasma	With Plasma
Wire	No Wire; thermal simulation	No Wire; thermal simulation
Mold Compound	CEL 9240	CEL 9240
MSL 3 Pre Con	MSL 3 / 192 hrs @ 30degC/60% RH	



Pre CSAM



Post CSAM

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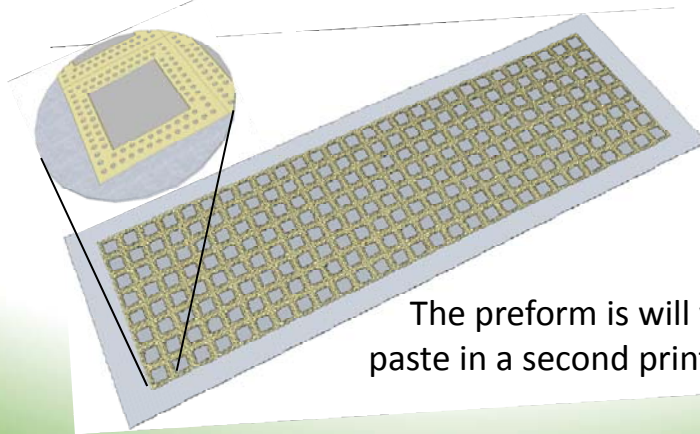




Manufacturing Process For EoPlex CSI™ LeadCarrier

Making an CSI™ LeadCarrier™

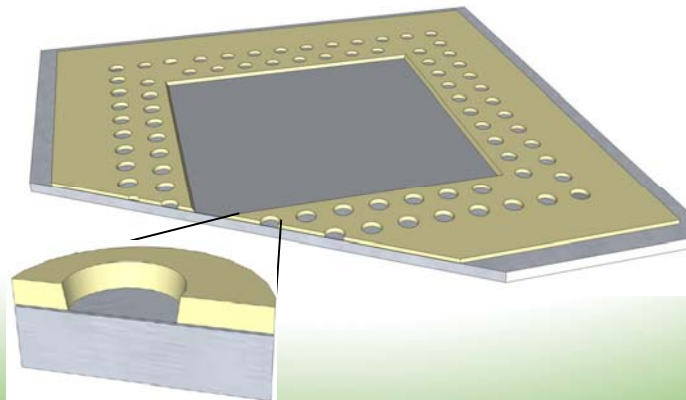
A precise sacrificial preform is print-formed to create the array of package sites



The preform is will with a silver paste in a second printing process

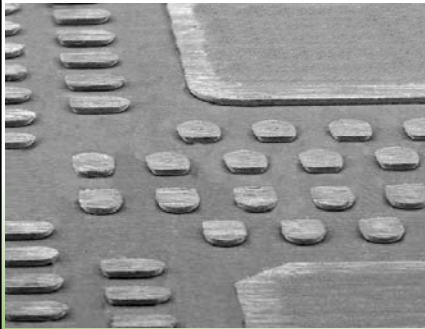
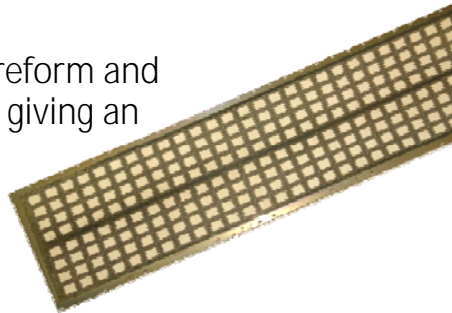
Creating the CSI™ Lock-in Feature

The preform is designed to yield sloped features to lock all pads into the mold compound



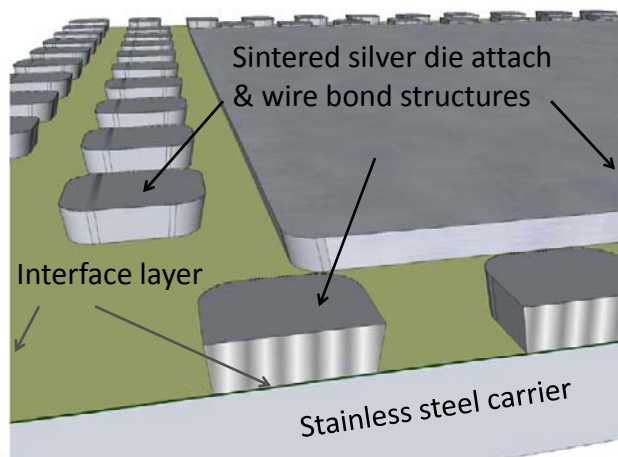
Remove the Preform & Sinter the Silver

Strips are fired to remove the preform and sinter the metal to high density, giving an excellent wire bonding surface



Result is an array of pads with excellent bonding surfaces, controlled adhesion to the carrier and a shape that locks the pads to the mold compound

Interface Chemistry: A Key to CSI™ Success



Chemistry of the interface layer provides good adhesion and clean release, with no treatment of solderable surfaces necessary.



Comparison to Standard Etched Leadframe

Relative to total cost of ownership

- Strip pricing: \approx 50% higher
- Strip utilization: As much as 50% greater
- No tape required
- Cut only thin EMC for singulation
- Test in strip is possible

Relative to performance metrics

- Multiple rows, up to around 500 leads
- Design freedom includes multi-chip, redistribution
- Minimum package thickness to 0.2mm vs 0.3mm
- No tie bar stubs = better electrical performance
- Very low thermal resistance
- Solderable lead flank as singulated

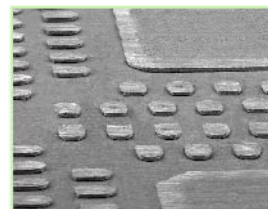
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Summary: EoPlex CSI™ Platform Driving a New Interconnect Paradigm

Final cost per lead up to 50% less

- Improves strip density by up to 50%
- No tape backing - saves cost and disposal
- Faster lower cost singulation - only plastic is cut
- Electrical testability in the strip after peel
- No plating or etching - "green process"
- Fits standard process



Improved performance, enables replacement of more expensive packages like BGAs

- Packages from 2 to 500+ leads
- Minimum metal = better electrical performance
- Excellent thermal performance
- Enables smaller and thinnest (200u) packages

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